# Kamran Keramatnejad

- Office Address: W145-G, Nebraska Hall, Department of Electrical and Computer Engineering, University of Nebraska-Lincoln City campus, Lincoln, NE68588-0511.
- Email Address: k.keramatnejad@huskers.unl.edu
- Website: <a href="http://lane.unl.edu/users/kamran-keramatnejad">http://lane.unl.edu/users/kamran-keramatnejad</a>
- Cell phone: 402-540-0472.

## I. Professional objective

> R&D Engineer (internship):

Seeking position as an assistant professor to utilize my teaching experience and research skills in the field of "Applied Physics" for educating and mentoring the students and helping them become the next generation of enthusiastic scientists and engineers.

II. Education	
> PhD Electrical Engineering (GPA: 3.9/4.00)	
University of Nebraska-Lincoln (UNL), Lincoln, NE, USA	Aug 2013 - Present
> MSc Applied Micro Electronics (GPA: 17/20 Among the top	_
Amirkabir University of Technology (AUT), Tehran, Iran	•
> BSc Electrical Engineering (Electronics) (GPA: 17/20 Top 4	
Isfahan University of Technology (IUT), Isfahan, Iran	•
III. Employment experience	• •
A. Academia	
> Research Assistant:	
Dept of Electrical and Computer Engineering, UNL	
Developed laser-based implantation method to fabricate CNT-coated copper cond	luctors with superior high-frequency electrical properties.
Designed and developed a laser-Assisted Nanowelding technique to improve	ve graphene-metal interfacial properties and electrical
performance in graphene devices.	
Developed and fabricated CNT-implanted conductors to reduce the arcing in elect	tromechanical devices.
> Teaching Assistant:	2014 2015
1. Dept of Electrical and Computer Engineering, UNL	
	ectromagnetic fields Theory
2. Dept of Electrical Engineering, AUT.	sers & Laser Applications
	miconductor Devices I
3. Dept of Electrical and Computer Engineering, IUT	
	ndamental of Electrical Engineering
> Course Lecturer:	Ç Ç
Dept of Electrical Engineering, AUT	2012 - 2013
Semiconductor Devices I	
<ul> <li>Theory and Technology of Fabrication of Semiconductor Devices</li> </ul>	
> Research Instructor:	
Nebraska Center for Materials and Nanoscience	
Supervised high school students summer program.	
B. Industry and University (Extracurricular)	
> Short projects funded by industry:	
Conductix Wampfler, Inc	Mar 2015 - Dec 2015
<ul> <li>Arc reduction in 3<sup>rd</sup> rail systems via dividing and weakening the discharge current</li> </ul>	
<ul> <li>Formation of micro-hole grids on the surface of the stainless steel rails via femtosecond laser drilling.</li> </ul>	
o Formation of CNT current channels <i>via</i> implanting CNTs on the laser-drilled micro-holes.	
> Lab Specialist:	
Semiconductors Laboratory, AUT	Sep 2010 - Aug 2013
<ul> <li>Designed and developed industrial gas sensors and optical detectors according to costumers' requirements.</li> </ul>	
> Maintenance Supervisor:	
DMD Inc: Cutting/abrasion division	Nov 2010 - Aug 2013
• Implemented CO <sub>2</sub> laser cutting systems for various metal based manufacturing an	d molding applications.

 Worked on LED pilot lights power improvement and power contactors for massive manufacturing. Also edited and published catalogue for these products in English.

# IV. Qualifications and Skills

#### A. Selected Research Skills

- Design and fabrication of novel devices with Carbon-based nanomaterials for achieving superior electrical properties.
- · Laser-processing of low-dimensional materials.
- · Femtosecond laser drilling of metals.
- · Laser-assisted growth of thin films.
- · Porous silicon-based UV detectors.

### B. Laboratory and Instrumentation

- Design and development of laser-processing experiments: CW/pulsed Lasers, 3D scanners, and optical path.
- Micro-fabrication: Lithography, Sputtering, CVD/MOCVD/LMOCVD. EPD, RTP.
- Optical sensors
- Structural characterization: SEM, AFM, Raman, XRD, surface profiler, optical microscope.
- Electrical characterization: four-point probe/two-point probe, I-V, S-parameters, AC resistance/reactance.

#### C. Computer and Programming

- Labview for controlling the movement of 3D/Galvo scanners in laser-processing setups.
- Experience in Matlab, Solidworks, Sisotools, Silvaco, H-spice, and ADS.

## V. Honors and Awards

- Graduate Student Conference Travel Grant, College of Engineering, University of Nebraska-Lincoln. ......................... Dec 2016
- Milton E. Mohr Graduate Fellowship, College of Engineering, University of Nebraska-Lincoln. ........ Sep 2015- Sept 2016
- Research Assistantship, National Science Foundation (NSF), Dept of Electrical and Computer Engineering, University of Nebraska-Lincoln.

  Aug 2013-present
- Ranked 213<sup>th</sup> (top 0.03%) among more than 700,000 participants in nationwide Undergraduate Entrance Exam of Universities in mathematics-physics branch.

  Aug 2006
- Ranked 99<sup>th</sup> (top 0.2%) among 42000 participants in nationwide Graduate Entrance Exam in Electrical Engineering. . . . . . . . May 2010

## **VI. Publications**

### A. Journal Articles

- 1. K. Keramatnejad, S. Zhou, D. W. Li, H. Rabiee Golgir, X. Huang, Q. M. Zhou, J. F. Song, S. Ducharme, Y. F. Lu, "Laser-Assisted Nanowelding of Graphene to Metals: An Optical Approach Toward Ultralow Contact Resistance", Submitted to Journal of Advanced Materials Interfaces.
- 2. K. Keramatnejad, Y. Gao, Y. S. Zhou, H. Rabiee Golgir, M. Wang, L. Jiang, J.-F. Silvain, Y. F. Lu, "Skin effect mitigation in laser processed multi-walled Carbon nanotubes/Cu conductors", Journal of Applied Physics 118.15 (2015): 154311.
- 3. H. Rabiee Golgir, Y. S. Zhou, K. Keramatnejad, W. Xiong, D. Li, M. Wang, L. Jiang, X. Huang, L. j. Jiang, J.-F Silvain, J. François, Y. F. Lu, "Resonant and nonresonant vibrational excitation of ammonia molecules in the growth of gallium nitride laser-assisted organic chemical vapor deposition". Journal of Applied Physics 120.10 (2016): 105303.
- **4.** H. Rabiee Golgir, Y. Gao, Y. S. Zhou, L. Fan, P, Thirugnanam, **K. Keramatnejad**, L. Jiang, J. F. Silvain, Y. F. Lu, "Low-Tempreture Growth of Crystalline Gallium Nitride Films Using Vibrational Excitation of Ammonia Molecules in Laser-Assisted Metalorganic Chemical Vapor Deposition", Journal of Crystal growth Design 14.12 (2014): 6248-6253.
- **5. K. Keramatnejad,** F. Khorramshahi, E. Asl-Soleimani, "Optimizing UV detection properties of n-ZnO NW/p-Si heterojunction photodetectors by using a porous substrate", Journal of optical and quantum electronics 47.7 (2015): 1739-1749.

#### **B.** Conference presentations:

- 1. K. Keramatnejad, Y. Gao, Y. S. Zhou, H. Rabiee Golgir, M. Wang, Y. F. Lu, "Skin Effect Suppression in Infrared-laser Irradiated Planar Multi-walled Carbon Nanotube/ Cu Conductors", ICALEO Conference Proceedings, Atlanta, GA (2015).
- **2. K. Keramatnejad**, S. Khatami, F. Raissi, F. Khorramashahi, "Highly sensitive PtSi/Si UV detector with high selectivity", Micro and Nanoelectronics (RSM) regional Symposium on. IEEE, Langkawi, Malaysia (2013): 194-196.

## VII. Activities

#### A. Voluntary work

- Private tutoring (undergraduate level mathematics, physics, chemistry)
- Community service at University Lutheran chapel.
- Volunteer judge for high school science fair.

## B. Hobbies

- Working out.
- Participating in dancing lessons.
- Studying 20<sup>th</sup> century history.

## VIII. References Available on Request